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Magnetic field dependence of threshold electric field for magnetoelectric switching of exchange-bias polarity

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We report the magnetic field dependence of the threshold electric field $E_{th}$ for the magnetoelectric switching of the perpendicular exchange bias in Pt/Co/Au/Cr$_2$O$_3$/Pt stacked films using a reversible isothermal electric tuning approach. The $E_{th}$ values for the positive-to-negative and negative-to-positive switching are different because of the unidirectional nature of the interfacial exchange coupling. The $E_{th}$ values are inversely proportional to the magnetic-field strength, and the quantitative analysis of this relationship suggests that the switching is driven by the nucleation and growth of the antiferromagnetic domain. We also find that the magnetic-field dependence of $E_{th}$ exhibits an offset electric field that might be related to the uncompensated antiferromagnetic moments located mainly at the interface. Published by AIP Publishing. [http://dx.doi.org/10.1063/1.4991053]

I. INTRODUCTION

Recently, the electric field control of perpendicular magnetization based on magnetoelectric (ME) insulator films has been receiving much interest for the realization of advanced spintronic devices with superior advantages such as high integration, high processing speed, and low power consumption.\textsuperscript{1–7} Antiferromagnetic (AFM) Cr$_2$O$_3$, which is a type of ME insulator, generates a perpendicular exchange bias (EB) when coupled with a ferromagnetic (FM) layer.\textsuperscript{7,8} Owing to the unidirectional nature of exchange coupling at the FM/AFM interface, the EB manifests itself through a shift of the unidirectional nature of the interfacial exchange coupling.\textsuperscript{14} The structural characterization was done using X-ray diffraction. The magnetic properties were analyzed using reflection high-energy electron diffraction (RHEED) and X-ray diffraction. The magnetic properties were analyzed using vibrating sample magnetometry and magneto-optic Kerr effect magnetometry. More details on sample preparation and structural and magnetic characterization can be found in our previous paper.\textsuperscript{14}

The Pt(1.2)/Co(0.4, 0.6)/Au(0.5)/Cr$_2$O$_3$(150, 200)/Pt(20) stacked films were prepared on $\alpha$-Al$_2$O$_3$(0001) substrates through DC magnetron sputtering. The base pressure of the sputtering chamber was maintained below 10$^{-5}$Pa. First, the Pt(111) buffer layer was deposited at room temperature (RT) and annealed for 1 h at 873 K. Then, the Cr$_2$O$_3$(0001) layer was deposited on the Pt(111) buffer layer at 773 K under a flow of mixed argon and oxygen. The Au spacer, the FM Co layer, and the Pt capping layer were deposited at RT under argon gas flow. The Au layer between Co and Cr$_2$O$_3$ layers was used to control the interface exchange coupling energy, which is necessary, so that the exchange bias persists up to the high temperature regime in which the ME control of the exchange bias is accessible. The Au spacer layer is also effective in getting perpendicular interfacial spins which result in high $E_{th}$ values for the ME switching of the perpendicular EB in a Pt/Co/Au/Cr$_2$O$_3$/Pt system using a reversible isothermal electric tuning approach. The ME switching energy conditions are studied further under different magnetic-field-cooling (FC) conditions in order to explore the intrinsic behavior of ME switching.

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\[ E_{th} = \text{constant} \]
The isothermal switching of EB polarity was investigated by conducting anomalous Hall effect (AHE) measurements on a microfabricated Hall device of width 2 μm and length 40 μm, fabricated by photolithography, Ar ion-milling techniques, and lift-off processes. The optical microscopy image of the fabricated device along with the measurement setups is shown in Fig. 1. In our device, the electric field was varied by changing the bias voltage applied across the Cr₂O₃(0001) layer between the top electrode (Pt cap layer) and the bottom electrode (Pt buffer layer). The magnetic field was applied in a direction perpendicular to the surface normal. The positive direction of the field was defined as the direction from the bottom electrode to the top electrode of the device. The energy condition for ME switching was studied after an FC process from 310 K to the measurement temperature, under different cooling fields of −6 kOe, +6 kOe, and +10 kOe. The ME switching was measured at 275–285 K by changing $E$ from −733 kV/cm to +750 kV/cm, while keeping the $H$ field at one of these values: +60 kOe, +50 kOe, +45 kOe, +40 kOe, −40 kOe, −45 kOe, −50 kOe, −55 kOe, or −60 kOe. To check the EB polarity after the aforementioned simultaneous application of both $E$ and $H$, the AHE loops were measured as functions of the perpendicular magnetic field in the range of ±1.5 kOe. During AHE measurements, the electric field was set to 0 kV/cm.

### III. RESULTS AND DISCUSSION

First, we show that the EB polarity is reversibly switched in an isothermal manner at 280 K, by varying $E$ under a constant magnetic field $H = +60$ kOe [Fig. 2(a)] for the Pt(1.2)/Co(0.4)/Au(0.5)/Cr₂O₃(150)/Pt(20) stacked film. The initial state is defined after the FC process under −6 kOe, and thus, the EB is initially defined in a positive direction (gray open circle). Starting from this positive EB state, the EB polarity is switched to negative after applying $E = −467$ kV/cm (blue closed circle). Then, from this negative EB state, the EB polarity is switched again to positive, by applying $E = +333$ kV/cm (red open square). The intermediate state, i.e., the partially switched state is also observed, for example, in the case of $E = −400$ kV/cm (green closed triangle). In the intermediate state, the two loops with negative and positive EBs are superimposed, indicating that the reversed and unreversed regions coexist. In an AHE loop, in addition to the change in the EB polarity, the remanence ratio reflecting the ratio of the two regions is also appropriate for evaluating the switching condition. Therefore, both values of the EB field $H_{EB}$ and the remanence ratio $M_R/M_S$ can be evaluated as functions of $E$, as shown in Figs. 2(b) and 2(c), respectively. To collect each data point, the device is initialized to the fully positive-EB (or negative-EB) state by applying $E = +333$ kV/cm (or −467 kV/cm) for the P-to-N (or N-to-P) switching process.

![FIG. 1. Optical microscopy image of the Hall device with the anomalous Hall effect (AHE) measurement setup.](image1)

![FIG. 2. (a) Typical ME switching of the exchange bias (EB) field under the magnetic field of $+60$ kOe at 280 K. The hysteretic electric field dependence of (b) EB field and (c) remanence ratio. All data were collected after a similar initial field cooling process under $−6$ kOe, more details are given in the main text.](image2)
The rectangular hysteresis is in agreement with the isothermal switching of the AFM domain state in Cr$_2$O$_3$. Similar behaviors are obtained at different constants $H$, i.e., $H = +50 \text{kOe}, +45 \text{kOe},$ and $+40 \text{kOe}$ [Figs. 2(b) and 2(e)]. From the hysteresis loop of $M_R/M_S$ [Fig. 2(c)], the $E_{th}$ values for both the P-to-N and N-to-P processes are estimated from the intersecting point of the loop with the horizontal axis, at which $M_R/M_S$ changes the sign. The asymmetry of the $E_{th}$ values between the N-to-P and P-to-N processes is attributed to the unidirectional nature of exchange coupling at the FM/AFM interface.

In order to assess the energy conditions of ME switching, we investigate the change in $E_{th}$ for a constant $H$ strength. In Fig. 3, the changes in $E_{th}$ are shown as functions of $1/H$, for both P-to-N (blue circle) and N-to-P switching (blue square). $E_{th}$ is inversely proportional to $H$, meaning that the $EH$ product is constant under the threshold conditions. This is simply interpreted as: the energy gain by the ME effect is expressed by $\alpha EH$, where $\alpha$ is an ME coefficient. To examine the ME switching conditions in more detail, we show the magnetic-field dependence of $E_{th}$ under different FC conditions: $+6 \text{kOe}$ (green circle and square) and $+10 \text{kOe}$ (black circles and square) in Fig. 3. The $E_{th}$–$1/H$ curves for different cooling fields show that $E_{th}$ is independent of both the cooling-field strength and the cooling-field direction, under the studied conditions. In other systems, it was reported that the $H_{EB}$ altered with the change in the cooling field; it was associated with the difference in the crystalline orientations of the AFM, or the coupling between the interfacial spins of the AFM layer with the external cooling field. In our research, the independence of the $E_{th}$–$1/H$ relationship from the cooling conditions implies the stability of the interfacial spin structure under the studied conditions.

In the previous report, the energy conditions for ME switching were assumed to follow the coherent rotation model, in which the ME effect led to an energy gain for switching the EB polarity. Under the application of external electric and magnetic fields, the total energy per unit area, including the magnetic anisotropy energy density $K_{AFM}$, the Zeeman energy, and the interface exchange coupling energy density $J$, is expressed as

\[ F = K_{AFM}E_{AFM} \sin^2 \theta - \alpha_{33}EH_{AFM} \cos \theta - JS_{FM}S_{AFM} \cos \theta, \]

(1)

where $t_{AFM}$ is the thickness of the AFM layer, $\alpha_{33}$ is the ME coefficient along the $c$ axis of Cr$_2$O$_3$, $S_{FM}$ and $S_{AFM}$ are the interfacial FM and AFM spins, and $\theta$ is the angle between the interfacial AFM and FM spins. Because the constant magnetic field $H$ was sufficiently higher than the saturation field of FM magnetization, $\theta$ can also be interpreted as the angle between the AFM spins and $H$. In the $E_{th}$–$1/H$ curves shown in Fig. 3, it can be observed that there is a shift in the $E_{th}$ intercept from the origin. As discussed below, this shift can be caused by the finite uncompensated antiferromagnetic moment, $M_{AFM}$, which is located at both the bulk site and the interface. As the $M_{AFM}$ at the bulk site, the pure magnetic switching of the interfacial $M_{AFM}$ and the resultant isothermal switching of the exchange polarity via the Zeeman energy are also possible. Hence, the Zeeman term of $M_{AFM}$ is reasonable to be considered and the Zeeman energy term for $M_{AFM}$ was added to Eq. (1), and then

\[ F = K_{AFM}E_{AFM} \sin^2 \theta - \alpha_{33}EH_{AFM} \cos \theta - JS_{FM}S_{AFM} \cos \theta - M_{AFM}H \cos \theta = K_{AFM}E_{AFM} \sin^2 \theta - (\alpha_{33}E_{AFM} + M_{AFM}H) \cos \theta - JS_{FM}S_{AFM} \cos \theta. \]

(1a)

The switching condition was derived from Eq. (1a) by minimizing the total energy per unit area. Namely,

\[ \frac{\partial F}{\partial \theta} = 0, \quad \frac{\partial^2 F}{\partial \theta^2} > 0. \]

(2)

The solution can be obtained for two different initial states, i.e., $\theta = 0$ or $\pi$. For each case, the energy condition can be simply expressed as

\[ \left( \alpha_{33}E + \frac{M_{AFM}}{t_{AFM}} \right)H = \frac{JS_{FM}S_{AFM}}{t_{AFM}}, \]

for P-to-N switching,

(3-1)

\[ \left( \alpha_{33}E + \frac{M_{AFM}}{t_{AFM}} \right)H = \frac{2JS_{FM}S_{AFM}}{t_{AFM}}, \]

for N-to-P switching.

(3-2)

Considering that the parameters in Eqs. (3-1) and (3-2) are constant as long as the temperature is maintained, Eqs. (3-1) and (3-2) suggest that the $E_{th}$–$1/H$ relationship should be linear. In addition, Eqs. (3-1) and (3-2) also suggest that the average and difference of the slopes of the $E_{th}$–$1/H$ curves yield $K_{AFM}/\alpha_{33}$ and $JS_{FM}S_{AFM}/(t_{AFM}\alpha_{33})$, respectively. From the results in Fig. 3, these values are estimated.

![FIG. 3. Magnetic field dependence of the threshold electric field for switching EB polarity for both P-to-N and N-to-P processes, under different cooling fields of $-6 \text{kOe}$ (blue marks), $+6 \text{kOe}$ (red marks), and $+10 \text{kOe}$ (black marks). The dashed lines are the guides to evaluate $E_{th}$.](image-url)
as $K_{\text{AFM}} = 4.5 \pm 0.6 \times 10^4 \text{erg/cc}$ and $J_{S\text{FM}}S_{\text{AFM}} = 1.5 \pm 0.2 \times 10^{-6} \text{erg/cm}^2$, respectively, assuming $\alpha_{33} = 3-4 \text{ps/m}$ at 280 K.\(^{(15, 19, 23, 24)}\)

Using the experimentally obtained $H_{\text{EB}}$ and $M_S$ values, $J_K$ at 280 K is estimated as $\sim 1 \times 10^{-3} \text{erg/cm}^2$, which is approximately one-third of the above estimated $J_{S\text{FM}}S_{\text{AFM}}$ value, which is in agreement with the well-known fact that the pinned spin model overestimates the exchange anisotropy energy density.\(^{9–11}\)

This is also consistent with our previous paper\(^{(27)}\) in which we showed that the interfacial uncompensated AFM (Cr) spins were not pinned but could reverse together with the FM spin reversal; the pinned spin model is not valid for our film.

Finally, we discuss the shift of the $E_0$ intercept from the origin, $E_0$ in the $E_{\text{th}}$-1/$H$ curves. According to Eqs. (3-1) and (3-2), $E_0$ should be proportional to $M_{\text{AFM}}/M_{\text{AFM}}$. Recently, Kosub et al. attributed $M_{\text{AFM}}$ to the defect-induced uncompensated AFM moment (emergent ferrimagnet) coupled with the AFM order parameter.\(^{(12)}\)

In our study, since the ME switching was detected through the exchange bias, $M_{\text{AFM}}$ should be considered as the AFM moments exchange-coupled with the FM spins. As long as the exchange bias is induced by the interfacial exchange coupling at the FM/Cr$_2$O$_3$ interface, it is reasonable to assume that the interfacial $M_{\text{AFM}}$ should have a significant role in $E_0$. According to our previous paper, the interfacial uncompensated Cr spins are antiferromagnetically coupled with the FM spins. Supposing the N-to-P switching for the positive magnetic field (blue dotted line in Fig. 3), the interfacial $M_{\text{AFM}}$ are antiparallel to $H$ (and FM spins) and $E$, and thus, $\alpha_{33}E$ and $M_{\text{AFM}}$ are antiparallel. Consequently, the $E_{\text{th}}$-1/$H$ curves shift toward negative, consistent with the experimental results.

From Fig. 3, one can find that there exists the following relationship:

$$E_0(N \rightarrow P, H > 0) \approx E_0(P \rightarrow N, H < 0),$$

$$E_0(P \rightarrow N, H > 0) \approx E_0(N \rightarrow P, H < 0).$$

$E_0$ for each case can be estimated as $-300 \pm 20 \text{ kV/cm}$ or $+100 \pm 5 \text{ kV/cm}$, depending on the sign of the constant $H$ field; $E_0$ is positive (negative) when the EB switches toward (against) the constant magnetic-field direction. According to Eqs. (3-1) and (3-2), the asymmetry of $E_0$ implies that there is a difference in $M_{\text{AFM}}$ for the P-to-N and N-to-P switching. When the $M_{\text{AFM}}$ are fully reversed in our exchange-biased system, $E_0$ would become symmetric, i.e., the absolute values of $E_0$ are similar for the N-to-P and P-to-N switching.

The previous report,\(^{(27)}\) we reported that the difference in $M_{\text{AFM}}$ and the asymmetric spin alignment with respect to the magnetic-field direction were present at the interface uncompensated AFM moments using the element-specific magnetization curve (ESMC) of Cr in the Pt/Co/Cr$_2$O$_3$/Pt exchange-biased film; the vertical shift of the ESMC curve of Cr. The vertical shift of ESMC causes the difference in $M_{\text{AFM}}$ for N-to-P and P-to-N switching, and consequently, $E_0$ becomes asymmetric. The direction of the vertical shift coupled with the polarity of the exchange bias, and among the absolute values of X-ray magnetic circular dichroism (XMCD) intensity, one could find the following relationship [see Fig. 3(b) of Ref. 27]

$$|M_{\text{AFM}}(N \rightarrow P, H > 0)| \approx |M_{\text{AFM}}(P \rightarrow N, H < 0)|,$$

$$|M_{\text{AFM}}(P \rightarrow N, H > 0)| \approx |M_{\text{AFM}}(N \rightarrow P, H < 0)|.$$

This similarity of the absolute value is consistent with the similar absolute value of $E_0$, i.e., the relationship shown in Eq. (4).

While in the above discussion, we focused on the interfacial uncompensated AFM moments, the defect-induced uncompensated AFM moment or the emergent ferrimagnet at the bulk site can also affect the interfacial AFM moments via the AFM order parameter. However, the existence of the emergent ferrimagnetism in our Cr$_2$O$_3$ film has to be investigated in more detail because no XMCD signal was observed in the Pt/Cr$_2$O$_3$/Pt/Ta/SiN membrane for both the surface-sensitive total electron yield method and the bulk-sensitive transmission methods in our previous paper.\(^{(28)}\)

As long as $M_{\text{AFM}}$ couples with the AFM order parameter, $M_{\text{AFM}}$ and $E_0$ depend on temperature. As shown in Fig. 4, the absolute value of $E_0$ increases with decreasing temperature except at 275 K for the N-to-P switching. The temperature dependence of $E_0$ may reflect that of $M_{\text{AFM}}$.\(^{(29)}\)
but it is a nontrivial problem. As mentioned above, both interface and bulk uncompensated AFM moments contribute to $M_{\text{AFM}}$, and these two can exhibit the different temperature dependence. Especially, the interface uncompensated AFM moments which should be the origin of the asymmetry of $E_0$ can possess a different critical exponent $\beta$ from that of the AFM order parameter.\(^29\) Hence, the symmetric and asymmetric contributions to $E_0$ can exhibit a different temperature dependence. In order to arrive at a definite conclusion for the temperature dependence of $E_0$, much more data points are necessary and further investigations are needed.

IV. SUMMARY

The magnetic-field dependence of $E_{th}$ for the ME switching of perpendicular EB in a reversible isothermal electric tuning approach was investigated. The $E_{th}$ was found to be inversely proportional to the magnetic field, agreeing with the ME-induced mechanism. The $E_{th}$ values were different for P-to-N and N-to-P switching processes, and this asymmetry originated from the unidirectional nature of the interfacial exchange coupling. The switching conditions were independent of the magnetic-field cooling conditions below the magnetic field strength of 10 kOe. The analysis of the $E_{th}/H$ relationship suggested that the ME switching was preceded by the antiferromagnetic domain motion. We also found that there was an offset electric field in the $E_{th}/H$ curve, and that it might have originated from the interfacial uncompensated AFM moments in Cr$_2$O$_3$.

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